## Valence band orbital polarization in III-V ferromagnetic semiconductors

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The element-specific technique of x-ray magnetic circular dichroism (XMCD) is used to directly determine the magnitude and character of the valence band orbital magnetic moments in (III,Mn)As ferromagnetic semiconductors. A distinct dichroism is observed at the As K absorption edge, yielding an As 4p orbital magnetic moment of around  $-0.1\mu_B$  per valence band hole, which is strongly influenced by strain, indicating its crucial influence on the magnetic anisotropy. The dichroism at the Ga K edge is much weaker. The K edge XMCD signals for Mn and As both have positive sign, which indicates the important contribution of Mn 4p states to the Mn K edge spectra.

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Magnetocrystalline anisotropy (MCA) plays a central role in technological applications of ferromagnetism, from permanent magnetic materials to ultrathin films. Since the MCA influences properties such as domain wall width, spin transfer torque, and magnetization dynamics, it is crucial for determining the spintronic functionalities of a material. The MCA has at its heart the spin-orbit interaction leading to a coupling between the magnetization and the crystal lattice. The MCA energy is directly related to the anisotropic part of the spin-orbit interaction, and is shown to be proportional to the difference in the orbital magnetic moment  $m_{\text{orb}}$  along the easy and hard magnetic axes when one of the spin subbands is filled.<sup>2</sup> In cubic transition metal ferromagnets, the MCA is typically rather small (corresponding to a few  $\mu eV$  per atom<sup>3</sup>), but may be substantially enhanced when the symmetry of the system is reduced.<sup>4</sup> Several new insights into the origin of MCA in a range of materials have been delivered by x-ray magnetic circular dichroism (XMCD) and x-ray magnetic linear dichroism due to their element-specific sensitivity to orbital moments<sup>5</sup> and spin-orbit coupling anisotropies, 1,6,7 respectively.

A particularly interesting MCA is found in diluted magnetic semiconductors such as  $Ga_{1-x}Mn_xAs$ , where a carriermediated interaction between Mn acceptors leads to ferromagnetic order, with a Curie temperature  $T_C$  up to 173 K for  $x \approx 7\%$ . At low concentrations, Mn acceptors in GaAs possess a  $d^5$  electronic configuration, with negligible single-ion anisotropy associated with the Mn core.8 However, in the high concentration ferromagnetic regime, a large uniaxial MCA is observed, which is strongly influenced by epitaxial strain.<sup>9</sup> The MCA in (Ga,Mn)As has been explained semiquantitatively by considering the combined effects of strain and exchange splitting on a model valence band built from s, p orbitals of the host ions.  $^{10,11}$  Within this model, the MCA (and related anisotropic magnetoresistance effects<sup>12</sup>) results from the induced anisotropy of the strongly spin-orbit coupled (j=3/2) valence hole states, with predominantly As 4p character. The model also predicts a sizable magnetization of the hole subsystem, of opposite sign to the Mn magnetization.<sup>13</sup>

Ab initio calculations generally agree that the ferromagnetism in (Ga,Mn)As is mediated by an antiferromagnetic p-d exchange coupling, but also point to a significant d character of the valence band holes.  $^{14-16}$  The amount of d weight at the Fermi energy depends strongly on the details of the calculations, and different studies yield values of the p-d coupling which may differ by as much as a factor of 2. Also, due to computational effort required, ab initio calculations generally do not include spin-orbit effects and, thus, are unable to account for the observed magnetic anisotropy. Multiband tight-binding calculations incorporating spin-orbit interaction suggest that hybridization between Mn 3d and GaAs valence bands results in resonances with strong orbital polarization close to the valence band edge.  $^{17}$ 

The antiferromagnetic coupling between Mn local moments and holes has been reported in optical magnetic circular dichroism studies. 18 However, since such measurements involve interband transitions, a direct element-specific and shell-specific determination of the states involved in the transitions is not possible. More recently, As and Ga  $L_{2,3}$  edge XMCD studies clearly demonstrated the presence of induced magnetic moments on the host ions. 19 Here, the excitation is from the 2p core level of either As or Ga, which are separated in energy by ≈230 eV, allowing an element-specific assignment of the measured signals: it was found that the As signal is larger than the Ga signal by a factor of  $\sim 7$  and opposite in sign. However, due to the electric-dipole selection rules governing the transition (specifically,  $\Delta l = \pm 1$ ), the 4p valence holes, which are the principal states governing the spintronic functionalities of the material, are not probed in *L*-edge absorption.

Here, we exploit K-edge XMCD to directly probe the magnetic anisotropy of the 4p valence states in (III,Mn)As ferromagnetic semiconductors. Since K-edge absorption involves excitations from the 1s (l=0) core level, a significant XMCD will occur only if there is an orbital polarization of the probed valence states. We present the first direct determination of the As and Ga 4p orbital magnetic moments in III-V ferromagnetic semiconductors.

The penetration depth of x rays at the Ga and As K edges is several tens of microns, which is much larger than the thickness of typical (Ga,Mn)As films. Therefore, Ga and As absorption signals from the substrate must be avoided. We investigated two different samples: (a) 1  $\mu$ m thick (Ga,Mn)As film grown on an AlAs buffer layer on GaAs(001), released from the substrate by etching the AlAs layer, and remounted on sapphire; and (b)  $0.5 \mu m$  thick (In,Ga,Mn)As film on InP(001), which is nearly lattice matched to the substrate by varying the In content in the film.<sup>21</sup> X-ray diffraction measurements show that the latter film is under small compressive strain. The films were grown by low-temperature (200–250 °C) molecular beam epitaxy, and the nominal Mn concentration (estimated from the Mn flux during growth) was  $\sim$ 8%. Superconducting quantum interference device magnetometry measurements show that the (Ga,Mn)As and (In,Ga,Mn)As films are ferromagnetic with  $T_C$  of 54 and 25 K, respectively.

The XMCD measurements were performed on ID12 of the European Synchrotron Radiation Facility (ESRF) at Grenoble. Ga, As, and Mn K-edge absorption spectra were obtained from total fluorescence yield measurements using 98% circularly polarized x rays. The XMCD signal was obtained from the difference in absorption for parallel and antiparallel alignments of the x-ray polarization vector with respect to an external magnetic field. Measurements, taken over several hours, were averaged in order to improve the signal-to-noise ratio. To avoid experimental artifacts, the external magnetic field direction and the x-ray helicity were alternately flipped. The measurements were performed at a sample temperature of 10 K, under a magnetic field of  $\pm 2$  T along the beam, which was either perpendicular or at grazing incidence (15°) to the sample surface. Self-absorption effects are accounted for in the quantitative analysis, and are very small as the probing and escape depths are much larger than the film thickness.

Figures 1(a)-1(c) show the As *K*-edge absorption spectrum from the (Ga,Mn)As film, and the Ga and As *K*-edge absorption spectra from the (In,Ga,Mn)As film. A clear dichroism is observed at the onset of the As absorption edge, indicating a polarization of the As 4p states at the valence band edge. The position and shape of the XMCD spectrum are similar for the two films, and also qualitatively similar to the main feature observed in As  $L_3$  XMCD from (Ga,Mn)As.<sup>19</sup> From the positive sign of the dichroism, we are able to conclude that the As 4p orbital polarization is antiparallel to the net magnetization. We also observe a substantial anisotropy of the As XMCD for the strained (In,Ga,Mn)As film, with a larger signal for grazing incidence than for normal incidence. At the Ga edge, the XMCD is much weaker, and is scarcely visible above the noise level.

A magneto-optical sum rule relates the integrated XMCD signals across an absorption edge to element-specific orbital magnetic moments per atom.<sup>5</sup> However, a quantitative application of this rule requires an accurate knowledge of the number of occupied 4p states,  $n_{4p}$ , as well as a separation of the 1s to 4p and 1s to continuum contributions to the absorption edge. Here, we take  $n_{4p}$  to be equal to 3, and describe the continuum background by a step function positioned under the highest intensity point of the absorption spectrum.

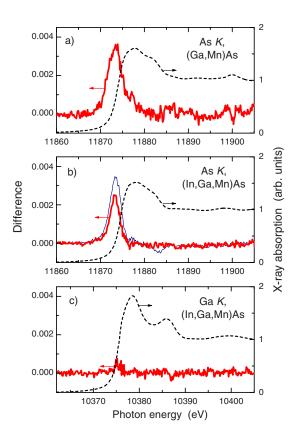


FIG. 1. (Color online) (a) XMCD spectra (drawn lines, left axes) and x-ray absorption spectra (dashed lines, right axes) for (a) As *K* edge of (Ga,Mn)As, (b) As *K* edge of (In,Ga,Mn)As, and (c) Ga *K* edge of (In,Ga,Mn)As. The thick red (gray) lines give the XMCD for normal incidence, and the thin blue (black) line in (b) gives the XMCD for grazing incidence.

Note that since the sum rule analysis is concerned only with integrated intensities, the precise shape of the background function is unimportant. Since the estimated 10%–20% uncertainties introduced by the above assumptions are systematic, the relative moments obtained from the different samples and orientations can be compared with good accuracy.

Results of the sum rule analysis are given in Table I. The obtained As 4p orbital moments are around  $10^{-3}\mu_B$  per As atom, while the Ga 4p orbital moment is an order of magnitude lower. From room temperature Hall effect measurements, we estimate that the hole concentration in the films is around  $10^{20}$  cm<sup>-3</sup>, in agreement with the values obtained at low temperatures and high magnetic fields for (Ga,Mn)As films with similar Mn doping.<sup>22</sup> Since the concentration of

TABLE I. As 4p and Ga 4p orbital magnetic moments ( $\times 10^{-3}\mu_B$  per Ga or As atom) obtained from sum rule analysis.

Magnetic moment	Direction	Sample (a) (Ga,Mn)As	Sample (b) (In,Ga,Mn)As
$m_{ m orb}^{ m As}$	Normal	$-1.3 \pm 0.2$	$-0.6 \pm 0.12$
$m_{ m orb}^{ m Ga}$	Normal		$-0.08 \pm 0.04$
$m_{ m orb}^{ m As}$	Grazing		$-1.0\pm0.2$

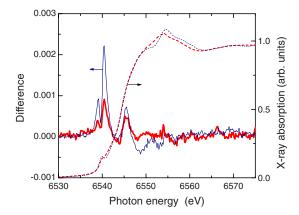


FIG. 2. (Color online) Mn *K* edge XMCD spectra (drawn lines, left axis) and x-ray absorption spectra (dashed lines, right axis) for (Ga,Mn)As [thin blue (black) lines] and (In,Ga,Mn)As [thick red (gray) lines].

As is around  $2 \times 10^{22}$  cm<sup>-3</sup>, this gives an As 4p orbital moment per valence band hole from around  $-0.1\mu_B$  to  $-0.2\mu_B$ .

For the (In,Ga,Mn)As film, the As 4p orbital moment at normal incidence is only  $\sim 60\%$  of the value obtained at grazing incidence. Since XMCD measures the projection of the orbital moment along the photon wavevector, the measured anisotropy indicates that, under a saturating magnetic field, the As 4p magnetization is larger for in-plane directions than for directions perpendicular to the plane. Model calculations have shown that in the absence of strain, the crystalline anisotropy of the hole magnetization is negligible. 13 Therefore, the observed anisotropy of the As 4p magnetization is ascribed to the small compressive strain. This leads to an in-plane easy magnetic axis, as confirmed by magnetometry and magnetotransport measurements. The magnetic easy axis is, therefore, aligned with the direction where the As 4p orbital moment is largest. In constrast to the As 4p moment, angle-dependent XMCD measurements at the Mn  $L_{2,3}$  edges of (Ga,Mn)As yielded no discernable anisotropy of the small Mn 3d orbital moment within the experimental uncertainty.<sup>23</sup> This indicates that it is the anisotropy of valence holes with As 4p character in (III,Mn)As ferromagnetic semiconductors that gives the dominant contribution to the MCA, in qualitative agreement with holefluid models of ferromagnetism in these systems. 10,11

Figure 2 shows the Mn K-edge x-ray absorption and XMCD spectra from the (Ga,Mn)As and (In,Ga,Mn)As films. The prominent part of the Mn XMCD consists of a double peak structure with a splitting of  $\sim 1.4$  eV, centered around the pre-edge feature in the x-ray absorption spectrum.

The Mn and As K-edge XMCD signals have the same sign and are comparable in magnitude.

Pre-edge structures are a typical feature of K-edge absorption spectra from systems with open 3d shells, and are usually associated with  $1s \rightarrow 3d$  transitions. While being formally electric-quadrupole transitions that are usually very weak, a stronger electric-dipole allowed character can mix in due to indirect hybridization between 3d and 4p orbitals on adjacent sites through the ligand states<sup>24</sup> or due to direct p-d hybridization on the excited atom. The latter mechanism may occur only in noncentrosymmetric environments, 25 such as the  $T_d$  symmetry of the Mn site in (Ga,Mn)As and (In,Ga,Mn)As. Mn  $L_{2,3}$  XMCD measurements have shown that the orbital and spin moments of the Mn 3d shell are parallel.<sup>23,26</sup> Therefore, the sign of the Mn K-edge XMCD is interpreted as being due to on-site mixing between Mn 3d and 4p states, where the Mn 3d and 4p orbital moments are antiparallel. Furthermore, since the Mn 4p shell is much less than half-filled, Hund's third rule implies that orbital and spin moments are antiparallel so that the Mn 3d and 4p spin moments are parallel.

Density-functional calculations of Ga, Mn, and As *K*-edge XMCD from (Ga,Mn)As have previously been reported.<sup>27</sup> While the magnitudes of the calculated XMCD for As and Mn are in reasonable agreement with our experimental results, the details of the spectra are rather different. In particular, the calculated Mn XMCD showed a sharp negative peak at the onset of the pre-edge,<sup>27</sup> which is absent in the experimental spectrum shown in Fig. 2. Such a feature is, however, observed in the XMCD spectrum of substitutional Mn in the wider band gap material GaN.<sup>28</sup> This suggests that the calculations of Ref. 27 have overestimated the *p-d* hybridization, giving a spuriously large Mn 3*d* component to the valence band hole.<sup>15</sup>

Comparing the present K-edge results to previous  $L_{2,3}$ -edge XMCD measurements of (Ga,Mn)As, we can draw some conclusions about the alignment of the element- and shell-resolved spin and orbital magnetic moments. These conclusions are summarized in Table II. As discussed above, the present results show that the As and Ga 4p orbital moments are antiparallel to the Mn 3d spin moment, and imply that the Mn 4p orbital and spin moments are, respectively, antiparallel and parallel to the Mn 3d spin moment. In addition, the Fermi energy is significantly lower than the spinorbit splitting of the valence band in the present samples, so that the valence holes have mostly j=3/2 character, with parallel orbital and spin moments of the Ga and As 4p shells. Elsewhere, Ga and As  $L_{2,3}$ -edge measurements indicated that their 4s spin moments are, respectively, parallel and antiparallel to the Mn 3d spin moment. 19 However, this interpreta-

TABLE II. Alignment of element- and shell-specific spin and orbital magnetic moments in (Ga,Mn)As, as determined from XMCD measurements. Note that the orientations of the As and Ga 4s moments (\*) are obtained from  $L_{2,3}$  edge measurements (Ref. 19), which (due to the dipole selection rule  $\Delta l = \pm 1$ ) could alternatively be interpreted as being due to As and Ga 3d spin moments.

	Mn 3 <i>d</i>	Mn 4 <i>p</i>	As 4s*	As 4p	Ga 4s <sup>⋆</sup>	Ga 4 <i>p</i>
$m_{ m spin}$	<b>↑</b>	<b>↑</b>	$\downarrow$	$\downarrow$	<b>↑</b>	$\downarrow$
$m_{\rm orb}$	$\uparrow$	$\downarrow$	0	$\downarrow$	0	$\downarrow$

tion neglects possible 2p to 3d transitions, which would give a contribution of opposite sign. Finally,  $\operatorname{Mn} L_{2,3}$  measurements have shown that the  $\operatorname{Mn} 3d$  spin and orbital moments are parallel.  $^{23,26}$ 

In summary, we have used x-ray magnetic circular dichroism to obtain the sign and magnitudes of the element- and shell-specific orbital magnetic moments in the III-V ferromagnetic semiconductors (Ga,Mn)As and (In,Ga,Mn)As. The large As 4p orbital polarization is shown to give the

important contribution to the strain-induced magnetic anisotropy in (III,Mn)As ferromagnetic semiconductors. These results will form a useful basis for the development of microscopic theories of spin-orbit coupling effects in ferromagnetic semiconductors and related systems. Technologically important phenomena in these materials rely on the spin-polarization and the magnetic anisotropy, and the modelling of these will ultimately need to conform to the correct magnetic coupling revealed by the present study.

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